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REPORT	
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COUNTRY SUBJECT

East Germany

Methods of Purifying Germanium for Use

in Transistors

PLACE **ACQUIRED**

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THIS IS UNEVALUATED INFORMATION

1. Purification of germanium and the making of germanium monocrystals for East German transistor develo ment is done at VEB Werk fuer Bauelemente der Nachrichtentechnik "Carl von Ossietzky" (formerly Dralowid), in Teltow, VEB Werk fuer Fernmeldewesen (formerly OGE), in Berlin-Oberschoeneweide, and in the Academy Institute for Research on the Physics of Solids in Berlin-Buch. The methods used in these three places are:

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- The Bridgeman method.
- The zone melting method.
- The Czrochalsky method.

The Dralowid plant obtained deliveries of 99.99% pure german-As of early November 1954, the enterprise had a supply of about one kilogram of germanium of the purity mentioned. This germanium of "Merck purity", as it is referred to in Germany, is processed in the following way according to the Bridgeman method. It is vacuum melted in a long, tube shaped quartz crucible. The crucible is connected to a drawing mechanism regulated by a clock, which draws the crucible out of the melting furnace at the slow speed of about. 1 millimeter per minute. Through this process, the germanium solidifies 3/ in such a way that its up er parts gradually become solid.

while the lower parts still exposed to the heat of he oven remain molten until they are also drawn cut. Inasmuch as imgaraties have a tendency to assumble in the molten part and to leave the parts which are in crystalization, the result of this operation is that the upper parts of the germanium will contain fewer impurities than the lower parts, where most of the impurities are ascembled. It has been found, for instance, that the ratio of antimony impurities within the crystalized germanium to those in the molten germanium is about 1 to 50. After the process is finished,

the solidified germanium is a monocristal. The next step is to decide which part of this monocrystal is suited for translstor purposes. For this purpose, an electrode is placed upon one

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longitudinal side of the monocrystal, whereas its other side as ccanned with a point-contact and the inverse voltage is thus measured. At the point where the inverse voltage reacher about 20V, the monoarystal is cut into the halves. The upper half is considered sufficiently pure for transister purposes. The lower half containing the impurities as again subjected to The same procdure. If the lower part contains too many importities, it is first treated chemically. The germanica is transformed into germanium dioxide (GsC2) or into germanium tetrachiorace (GeCl4). Germanium dioxide is then reduced to germanium with the aid of hydrogen. The germanium tetrachloride is first porified by fractional distillation and then decomposed hydrolytically, with germanium dihe latter substance is then reduced in the oxide reculting. described above. The Brelowid lant in applying this devod has succeeded in making germanium monocrystals with a maximum purity of 40 ohe centimeter,

The method described above is the only one which has been actually spolied in the Dralowid plant. Ho ever, as of early Hovember 1954 this plant was constructing an apparatus for the application of the "zore meltingprocedure" (Conenschmelzverfahren) and expected to reach purities up to 70 ohn centimeter with its aid. This procedure is ap lied to germanium monocrystals roduced by the Bridgeman method. The mono crystal with attachments on its upper and lower ends is brought into s cylindrically-shaped melting furnace (Ringofen). The upper and lover ends of the monocrystal are again connected to a drawing mechanism which is able to draw the crystal out at very slow speed. to the Bridgeman method, the crystal is not in a crucible so that impurities stemming from the walls of the crucible will not occur. Letween the inner walls of the oven and the crystal, there is a c_{ϵ} lindrically-shaped container able to insulate the crystal from the heat of the oven. This container is pierced horizontally so that the heat is allowed to pass through a circular shaped slit and can reach the correspending parts of the monocrystal. The monocrystal is drawn slowly out of the oven, and thus it is constantly malted only in the region determined by the position of the slit. Through this process, the impurities migrate to the parts below the slit. As a result, the impurities are assembled in the very lowest part of the monocrystal. The apparatus is rovided with an automatic temperature control which keeps the tem erature constant with a tolerance of plus or minus 10 Centigr The control is carried out with the aid of photocells. This apparatus was not quite com leted in early November 1954, but it w s expected to be completed before the end of the year,

The Czrochalsky method applied in the Academy Institute for Medicine and Biology in Berlin-Buch combines features of the two methods mentioned above. The germanium is put into an open-top ed crucible made of smoothite.

This crucible is first vacuum-heated for a period of three hours at a temperature of 2,000° Centigrade, in order to destroy impurities which it might possibly contain. The germanium metal is then vacuum metal in the crucible at about 1,000° Cantigrade. In its molten state the germanium forms a meniscus in the crucible. A point made of tungent is introduced into the meniscus and drawn out of it machanically at a speed of 0.2 to 2.0 millimeters per minute. In this way a pure germanium monocrystal is produced. Transistor work in the Institute has not progres ed beyond this stage.

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